PATENT APPLICATION

K. Brown

Group Art Unit: 2851

Docket No.: 104313.01

Examiner:

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Kazuya OTA et al.

Application No.: 09/846,304

Filed: May 2, 2001

APPARATUS AND METHOD FOR PATTERN EXPOSURE AND

METHOD FOR ADJUSTING THE APPARATUS

SUPPLEMENTAL AMENDMENT

Director of the U.S. Patent and Trademark Office

Washington, D.C. 20231

Sir:

For:

Further to the Amendment under 37 C.F.R. §1.111 filed on December 17, 2002, please further amend the above-identified application as follows:

IN THE CLAIMS:

Please replace claims 1, 23-25, 31, 42 and 43 as follows:

The following is a marked-up version of the amended claims:

1. (Twice Amended) A method for performing an optical adjustment on an exposure apparatus which exposes an object with exposure light from a light source, comprising:

generating, from said light source, non-exposure light having a wavelength which is different from that of said exposure light, said non-exposure light including at least one of ultraviolet light and visible light;

adjusting an optical property of an optical system through which said exposure light passes by receiving said non-exposure light from said light source through at least a part